
Status and progress of TPC module and prototype R&D in IHEP

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Outline

- Physics requirements
- Status of TPC module R&D
- Status of TPC prototype R&D
- Summary

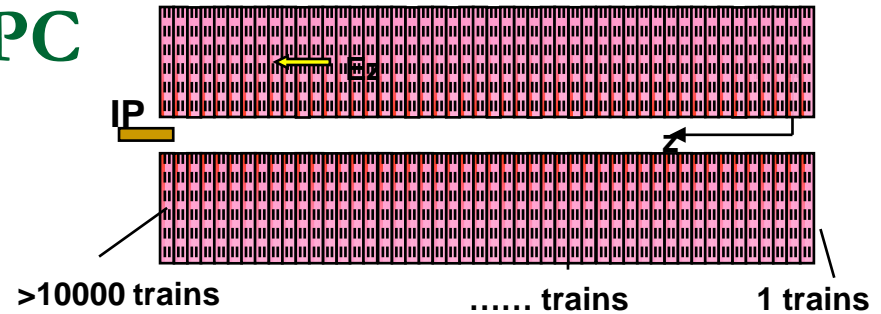
Technical challenges for TPC

Ion Back Flow and Distortion :

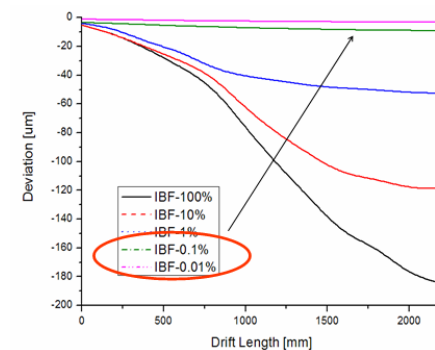
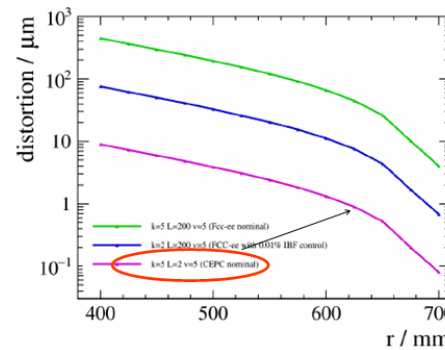
- ❑ $\sim 100 \mu\text{m}$ position resolution in $r\phi$
- ❑ Distortions by the primary ions at CEPC are negligible
- ❑ More than 10000 discs co-exist and distorted the path of the seed electrons
- ❑ The ions have to be cleared during the $\sim \mu\text{s}$ period continuously
- ❑ Continuous device for the ions
- ❑ Long working time

Calibration and alignment:

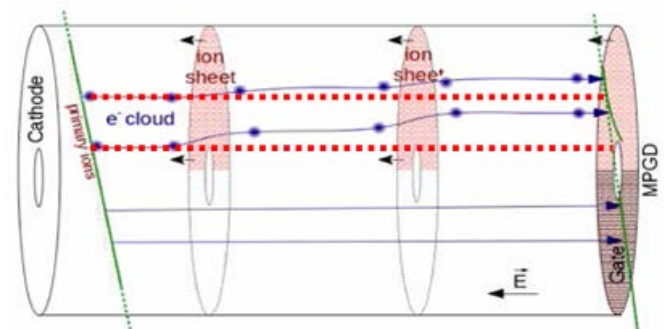
- ❑ Systematics precision ($< 20 \mu\text{m}$ internal)
- ❑ Geometry and mechanic of chamber
- ❑ Modules and readout pads
- ❑ Track distortions due to space charge effects of positive ions



Amplification ions @CEPC



Evaluation of track distortions



Ions backflow in drift volume for distortion

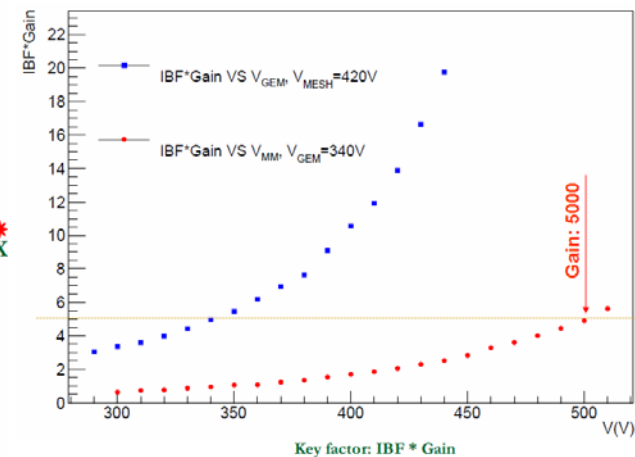
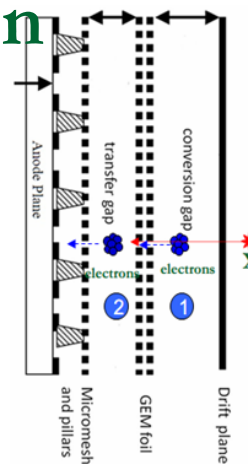
Options of technical solution

Continuous IBF module:

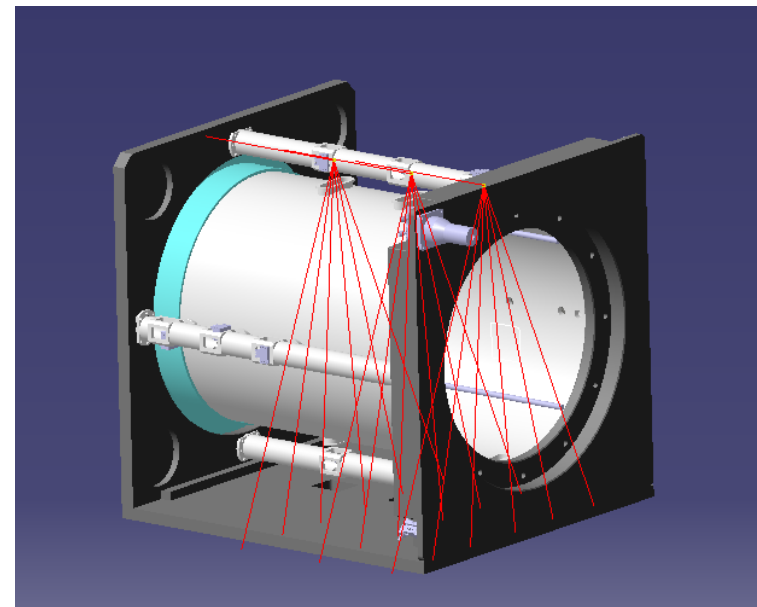
- ❑ **Gating device may be used for Higgs run**
- ❑ **Open and close time of gating device for ions: $\sim \mu\text{s}$ -ms**
- ❑ **No Gating device option for Z-pole run**
- ❑ **Continuous Ion Back Flow due to the continuous beam structure**
- ❑ **Low discharge and spark possibility**

Laser calibration system:

- ❑ **Laser calibration system for Z-pole run**
- ❑ **The ionization in the gas volume along the laser path occurs via two photon absorption by organic impurities**
- ❑ **Calibrated drift velocity, gain uniformity, ions back in chamber**
- ❑ **Calibration of the distortion**
- ❑ **Nd:YAG laser device@266nm**



Continuous IBF prototype and IBF \times Gain

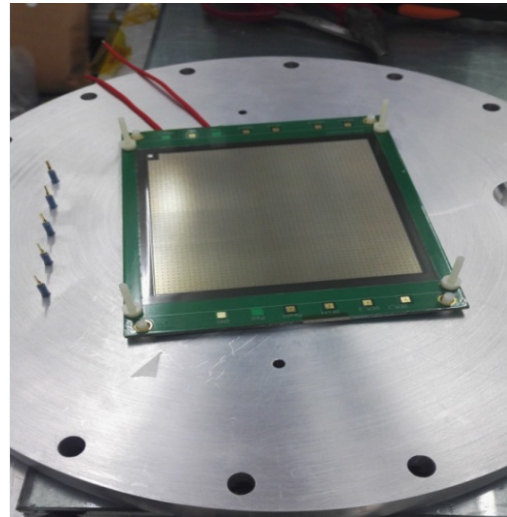
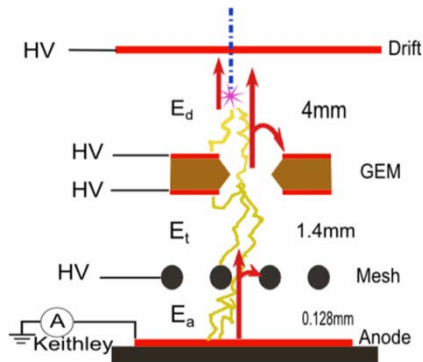


TPC prototype integrated with laser system

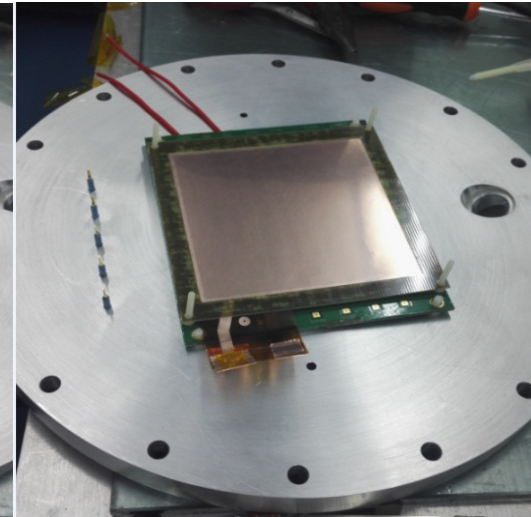
Investigation of IBF study with module

Test of the new module

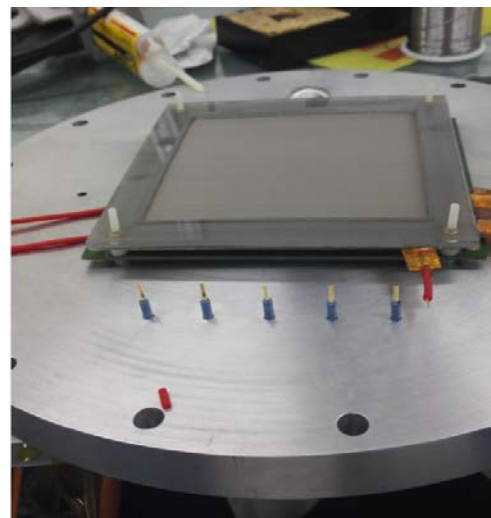
- Test with GEM-MM module
 - New assembled module
 - Active area: 100mm×100mm
 - X-tube ray and ^{55}Fe source
 - Bulk-Micromegas from Saclay
 - Standard GEM from CERN
 - Additional UV light device
 - Avalanche gap of MM:128 μm
 - Transfer gap: 2mm
 - Drift length:2mm~200mm
 - Mesh: 400LPI



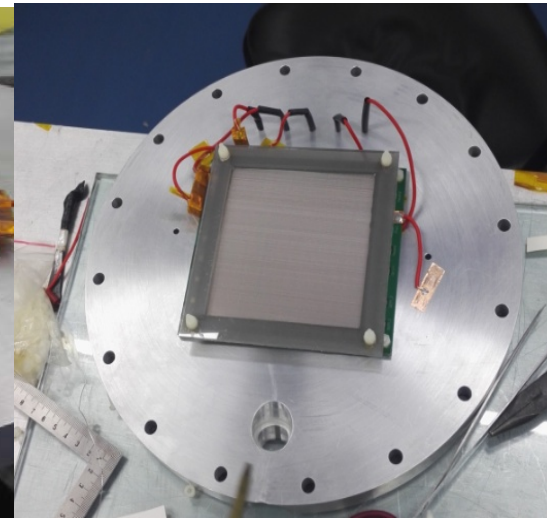
Micromegas(Saclay)



GEM(CERN)



Cathode with mesh



GEM-MM Detector

Electrometer/High Resistance Meter

Keithley 6517B

Electrometer/High Resistance Meter, 100aA
- 20mA, 10 μ V - 200V, 100 Ω - 10P Ω

Brand: Keithley

Model No: 6517B

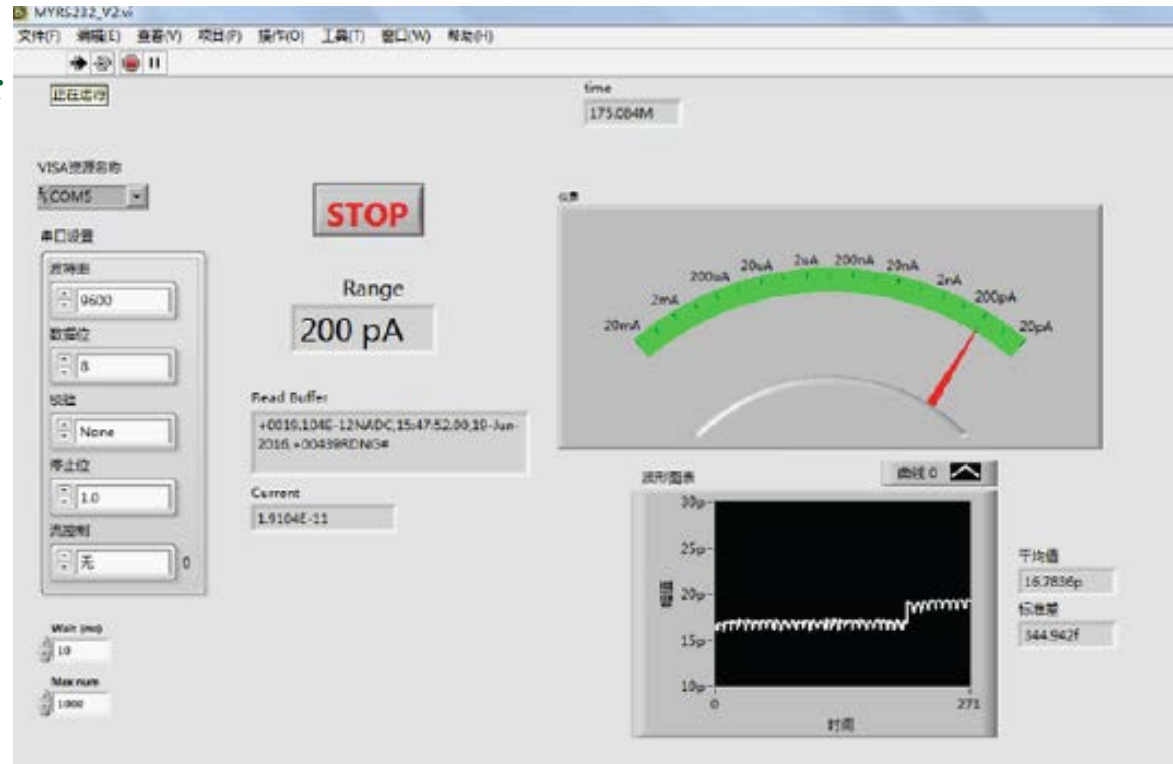


Product Features:

- Measures resistances up to 10180
- 10aA (10 \times 10-18A) current measurement resolution
- Less than 3fA input bias current
- 6 1/2-digit high accuracy measurement mode
- Less than 20 μ V burden voltage on the lowest current ranges
- Voltage measurements up to 200V with >200TO input impedance
- Built-in +/-1000V voltage source
- Unique alternating polarity voltage sourcing and measurement method for high resistance measurements
- Built-in test sequences for four different device characterization tests, surface and volume resistivity, surface insulation resistance, and voltage sweeping
- Optional plug-in scanner cards for testing up to 10 devices or material samples with one test setup

Measurement of GEM-MM module

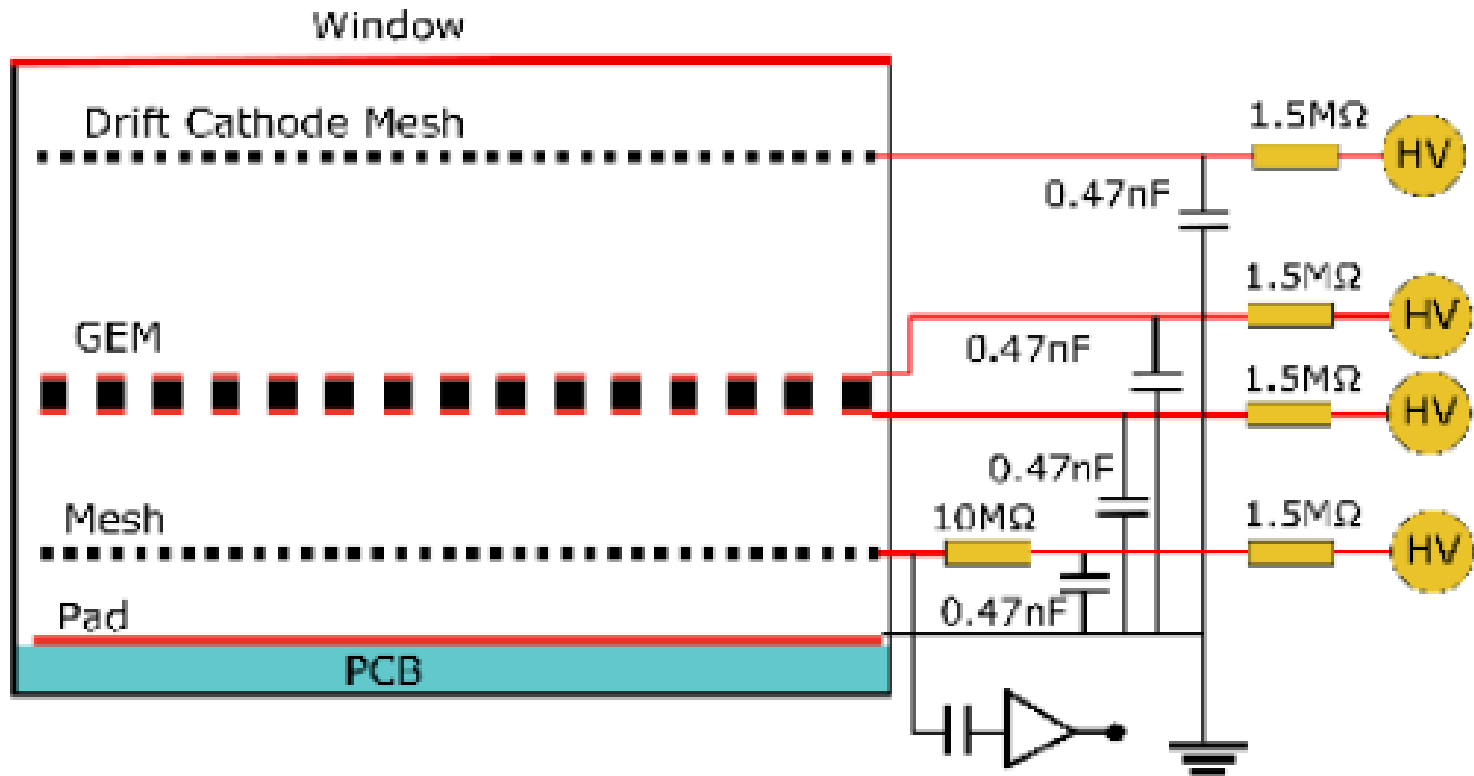
- Test with GEM-MM module
 - Keithley Electrometers for Ultra-Low Current Measurements: pA~mA
 - Keithley: 6517B
 - Test of cathode of the module
 - Test of readout anode of the module
 - Labview interface of the low current to make the record file automatically



Labview interface of the current with Keithley

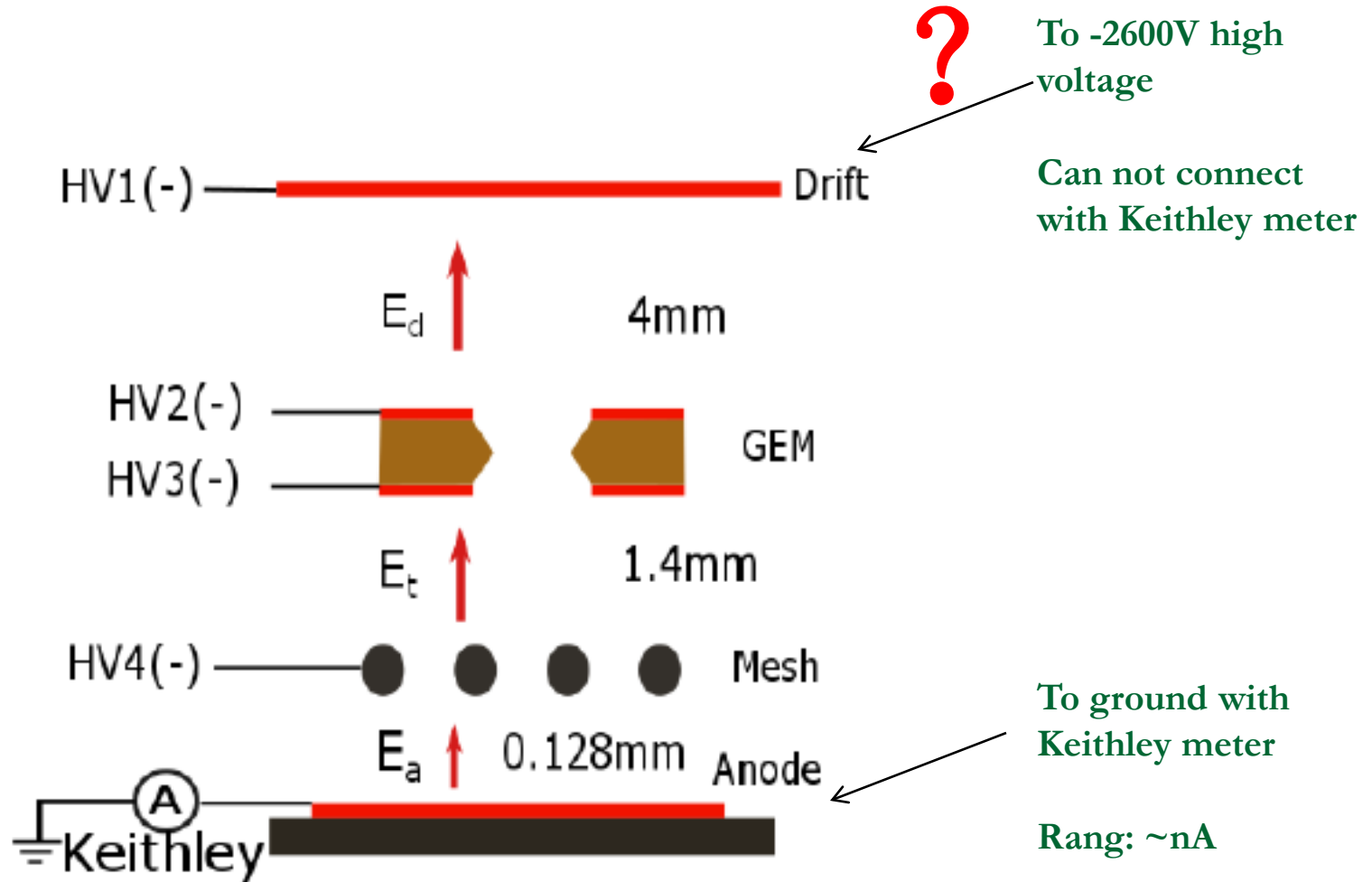
$$IBF = \frac{I_C - I_P}{I_A}$$

GEM-MM module

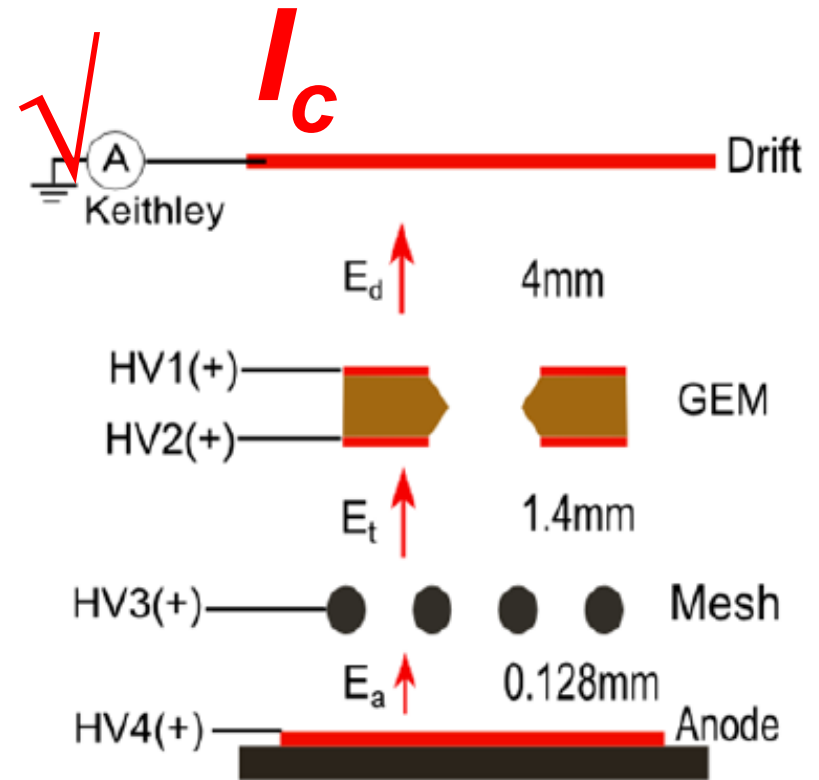
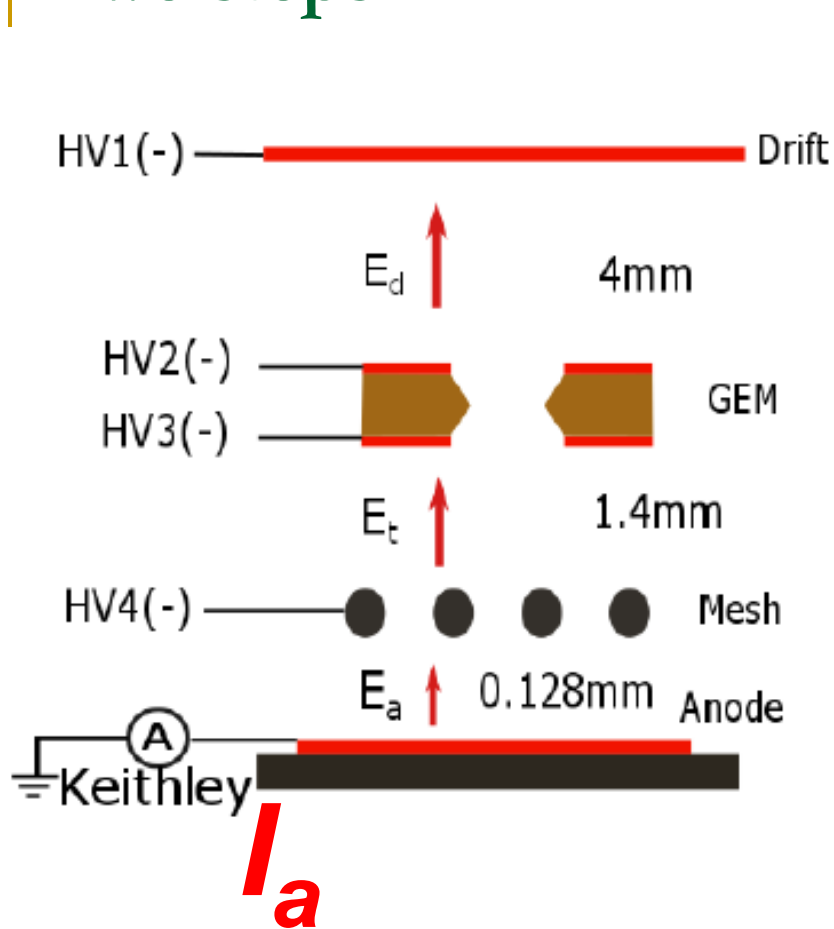


High voltage diagram of the detector module

First step

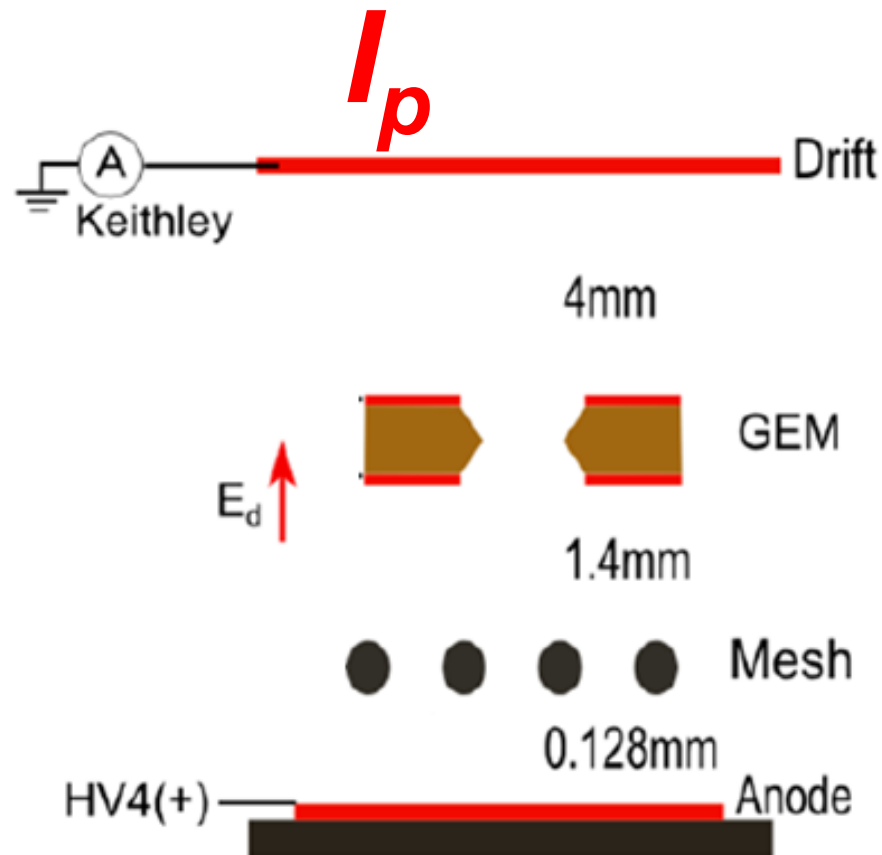


Two steps



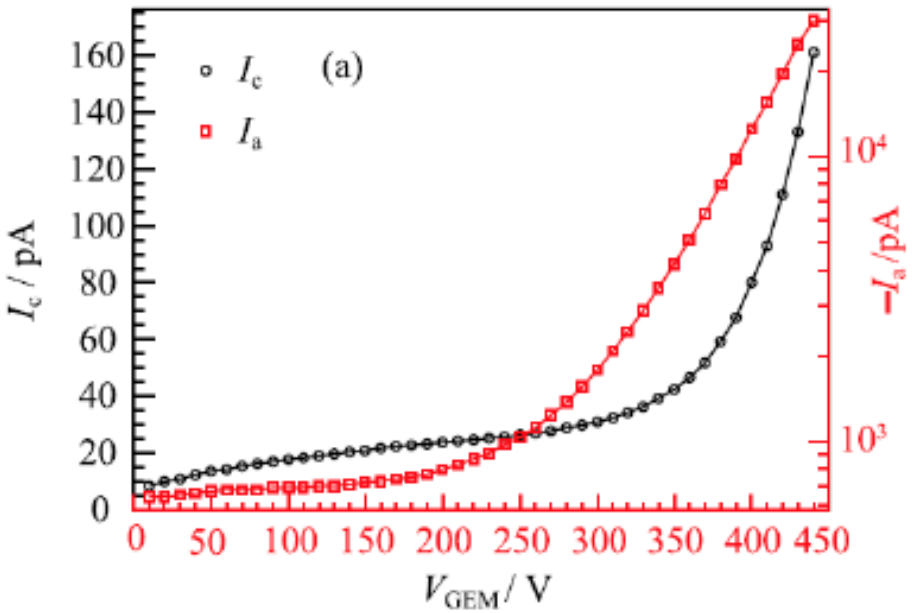
- Different polarity
- Same electric field
 - $E_d = E_d$; $E_t = E_t$; $E_a = E_a$

Primary electrons current

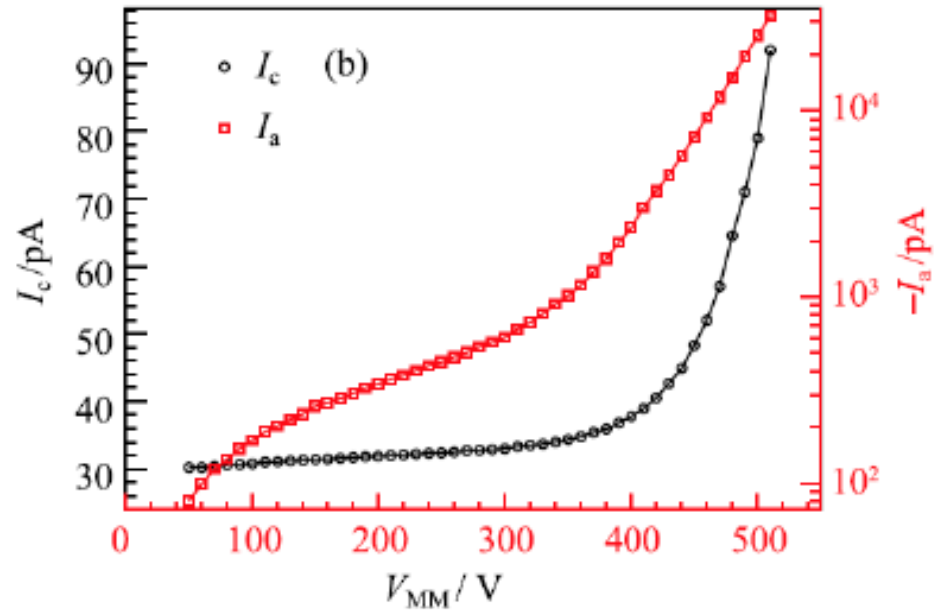


- No operation voltage of the GEM-MM detector
- Just test current of the primary electrons (\sim pA)

Ic and Ia



□ GEM with operation voltage



□ MM with operation voltage

IBF and Gain

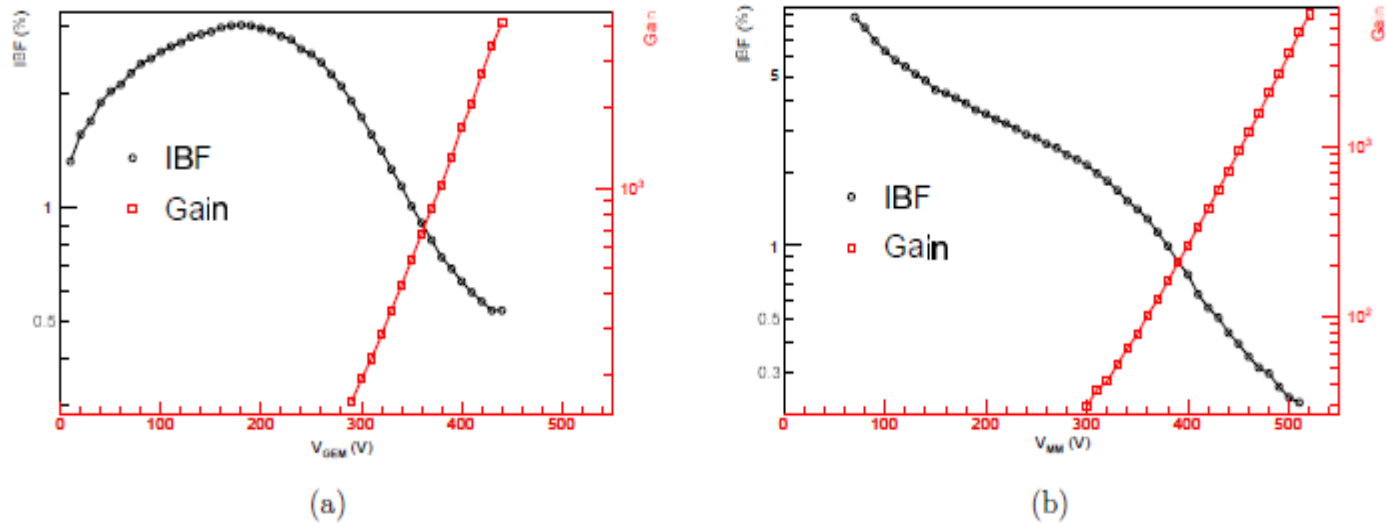


Fig. 4: (color online) Gas gain and IBF versus (a) GEM voltage, micromesh $V_{mesh} = 420$ V and (b) micromesh voltage, $V_{gem} = 340$ V. $E_d = 250$ V/cm, $E_t = 500$ V/cm.

Status of TPC prototype R&D

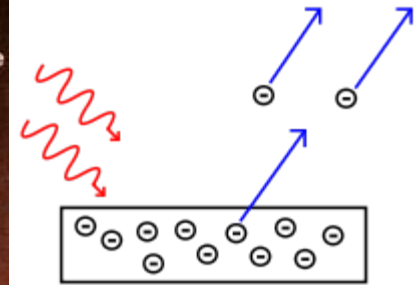
Parameters of the TPC prototype

- To aim that the small TPC prototype for the estimation of the distortion due to the IBF, and the study of related physics parameters
- To mimic the bunch structure & the ions distortion with UV light and laser split beam

- Main parameters
 - Drift length: 510mm
 - Readout active area: 200mm × 200mm
 - Integrated the laser and UV lamp device
 - Wavelength of laser: 266nm
 - GEMs/Micromegas as the readout
 - Materials: Non-magnetic material (Stainless steel, Aluminum)

Why UV light study

- ❑ IBF measurement methods
 - ❑ ^{55}Fe radioactive source
 - ❑ X tube machine
 - ❑ Synchrotron radiation
 - ❑ **UV light by the photoelectric effect**



Photoelectric effect

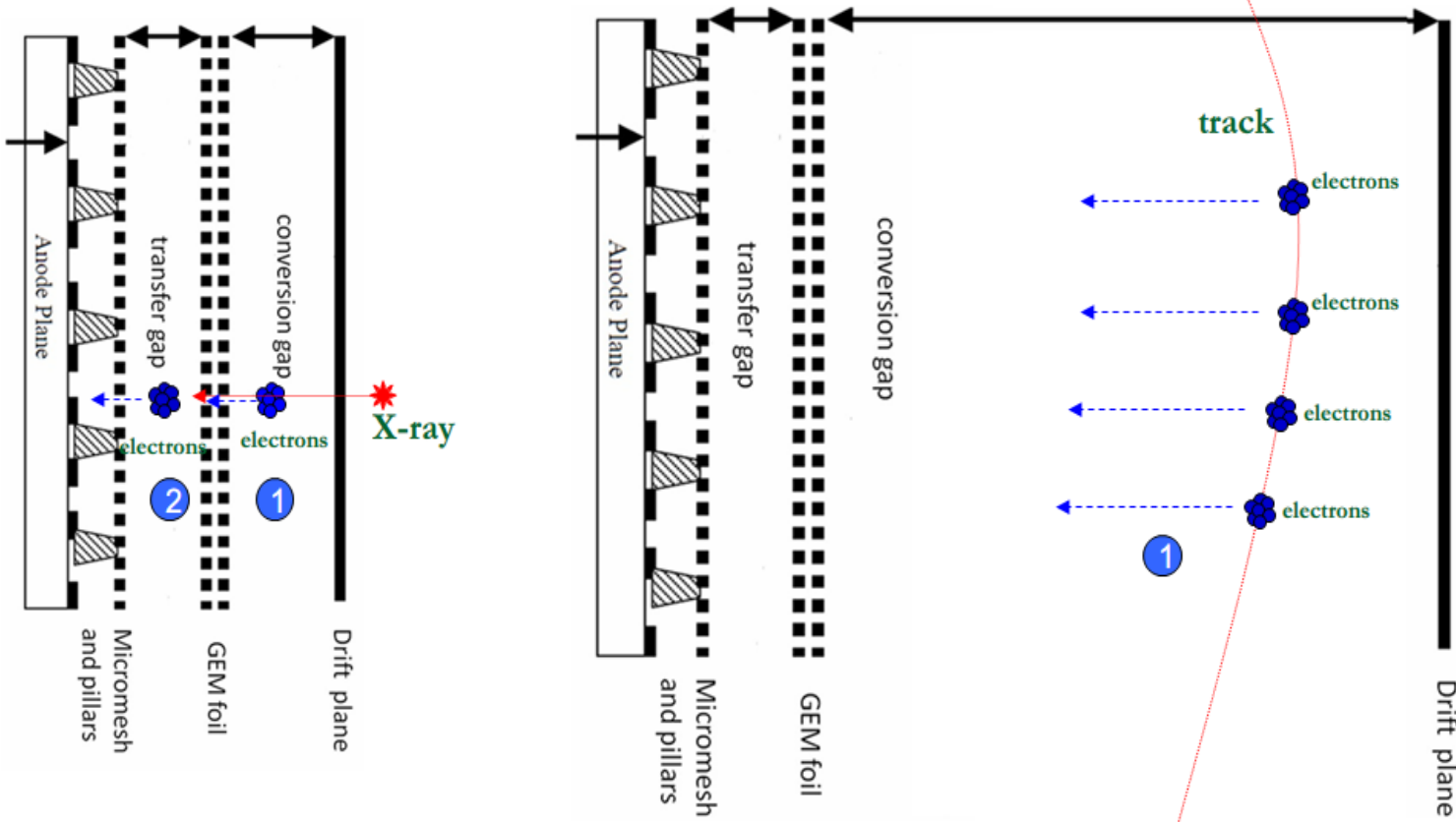


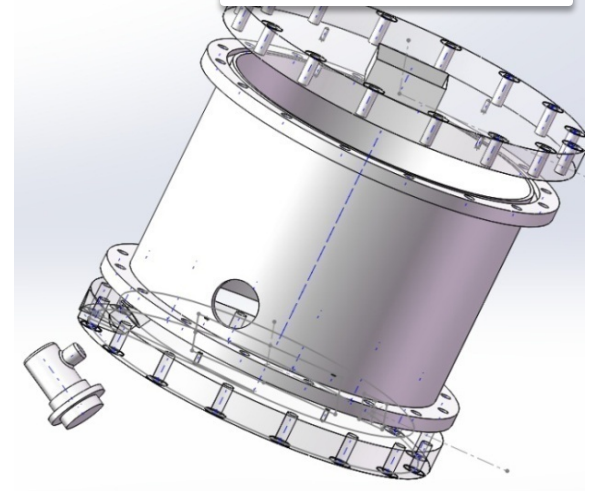
Diagram of the IBF test with the module

UV test of the new module

- UV lamp measurement
 - New designed and assembled UV test chamber
 - Active area: 100mm×100mm
 - Deuterium lamp and aluminum film
 - Principle of photoelectric effect
 - Wave length: 160nm~400nm
 - Fused silica: 99% light trans.@266nm
 - Improve the field cage in drift length



Deuterium lamp
X2D2 lamp



UV test geometry with GEM-MM

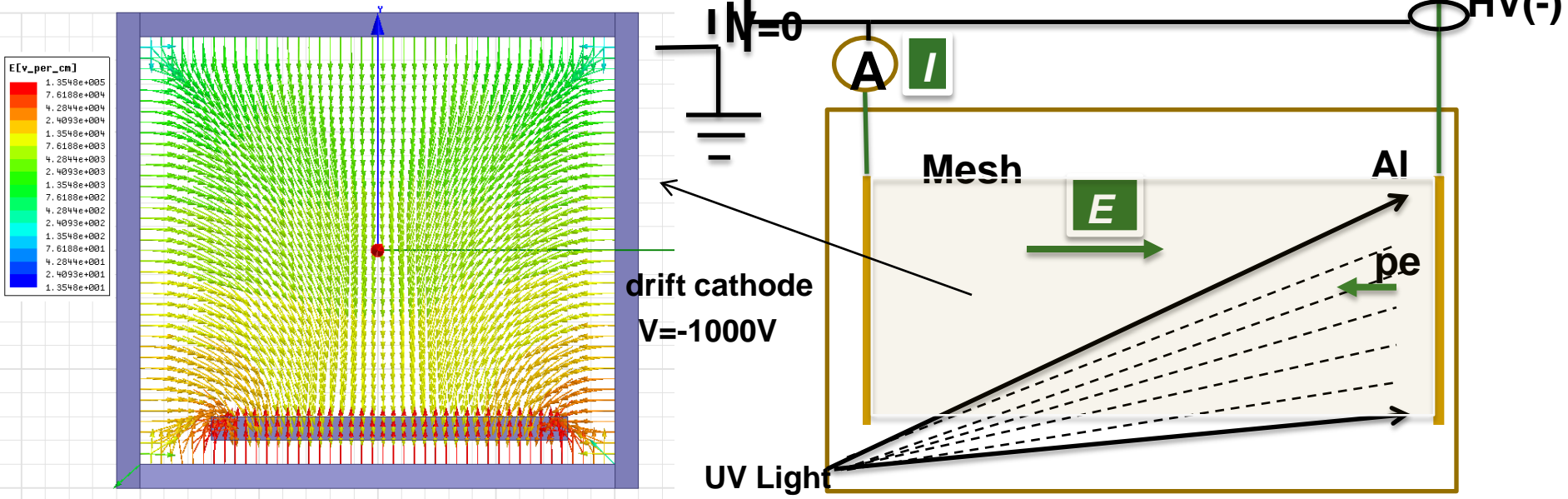
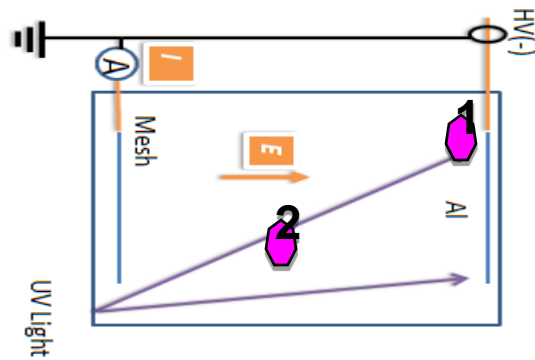


Diagram of the UV test with new module

Electrons produced by UV

- Re-mounted the UV light
 - Two mixture gases
 - High E test
 - Ar gas purity: 99.999%
 - iC4H10 gas purity: 99.99%
 - CO2 gas purity: 99.999%
 - CF4 gas purity: 99.99%
- About 31000 electrons/s.mm²
- Electrons from Al
- Electrons from drift length at 266nm UV light (~MIPs)



UV Shining diagram

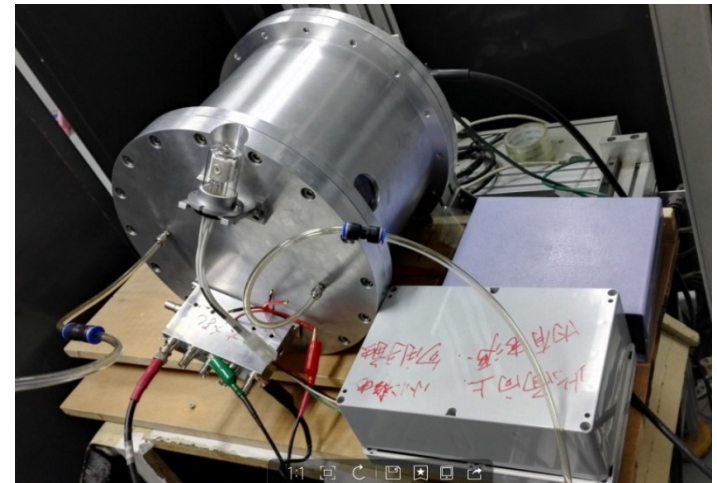
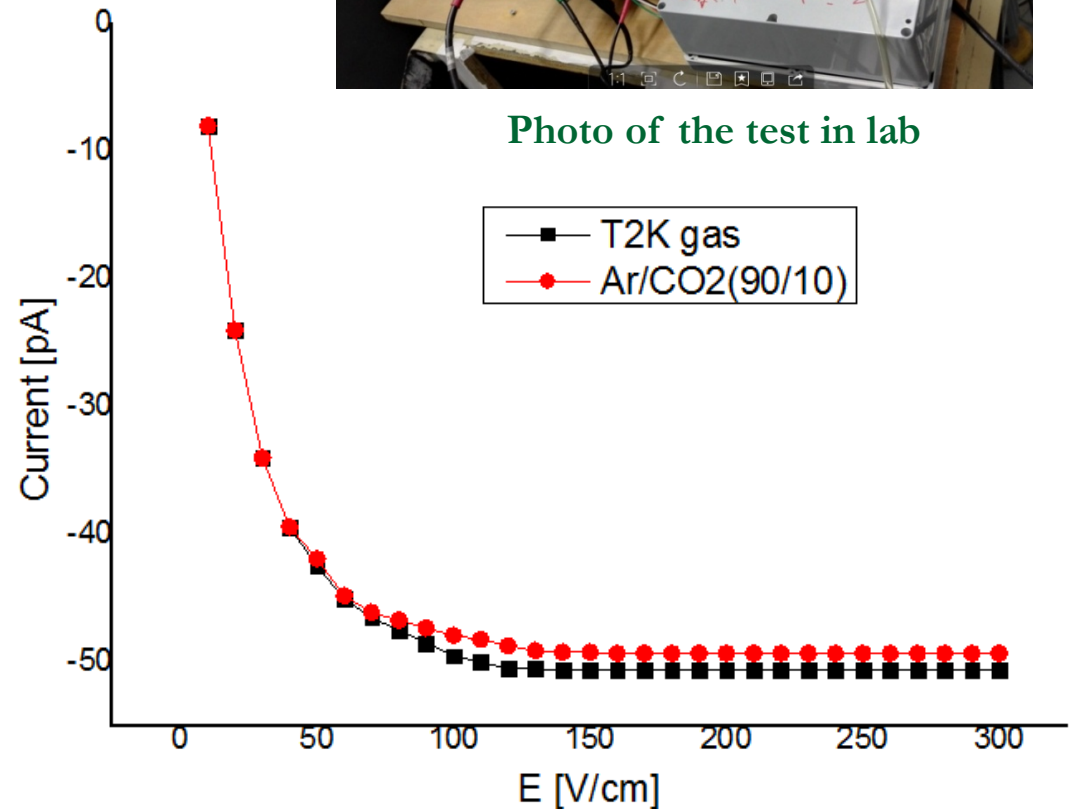
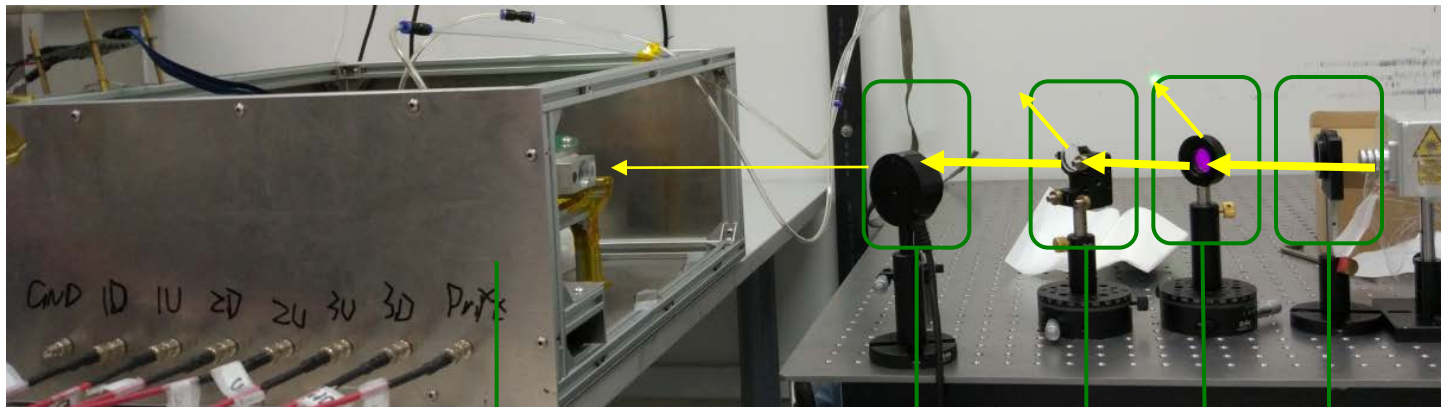


Photo of the test in lab



Current VS Electric field in drift length

Signal of the laser with $\Phi 1\text{mm}$ @266nm



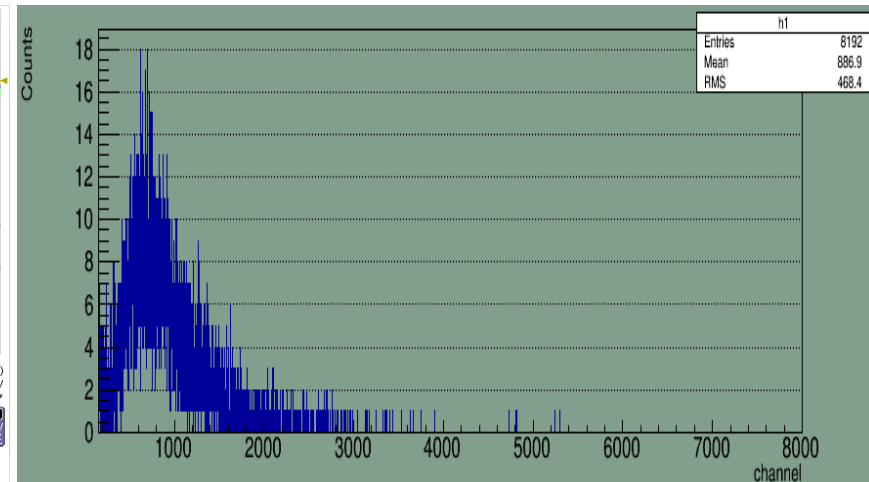
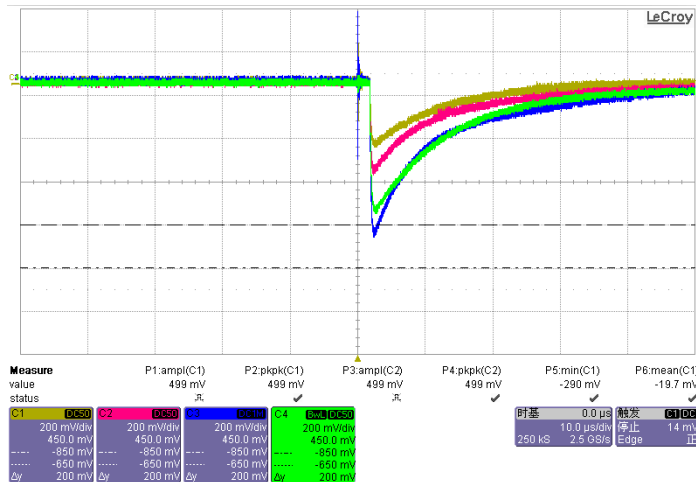
Triple GEMs
detector

Hole collimator
 $\Phi 1\text{mm}$

Trans/refle.
=1:99

Transmission
mirror

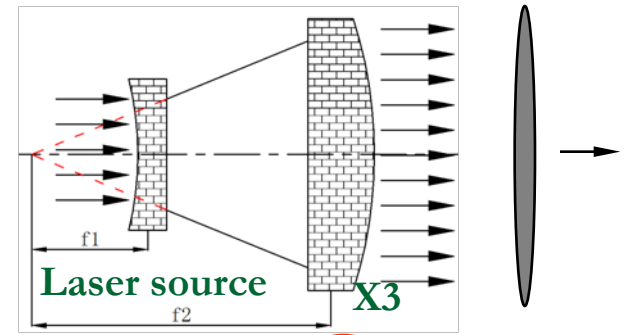
Transmission mirror



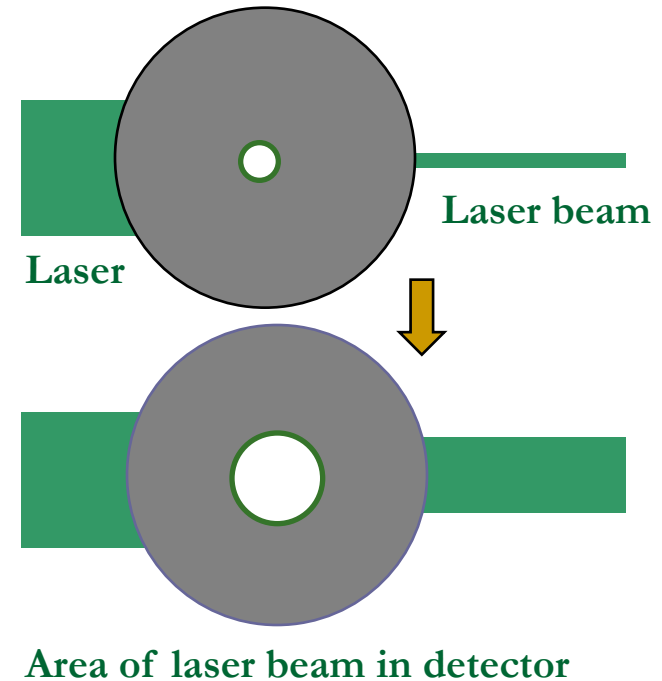
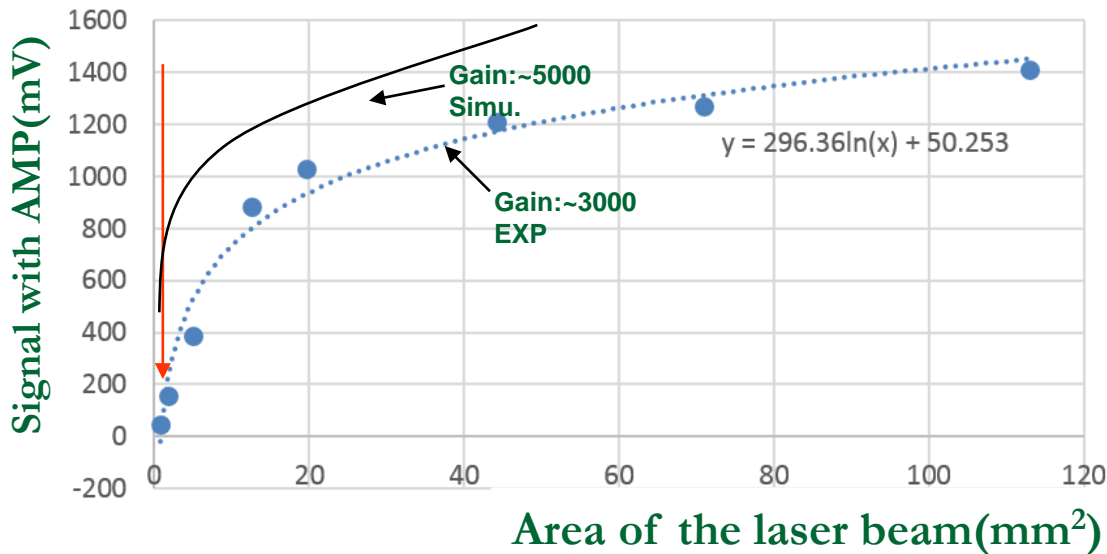
Signal of the laser with $\Phi 1\text{mm}$ @Charge sensitive AMP/12mV/fC

Collimator@ $\Phi 1 \sim \Phi 12\text{mm}$

- ❑ Laser beam with expander mirror: $5\text{mm} \times 3$
- ❑ Primary laser power: $170\mu\text{J}$
- ❑ Gain: ~ 3000

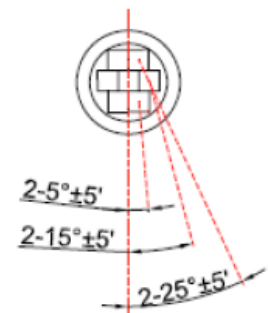
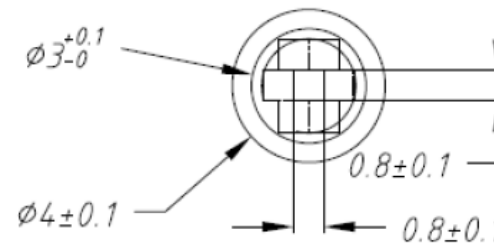
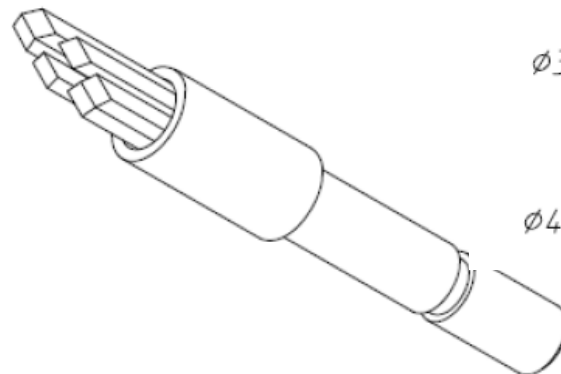
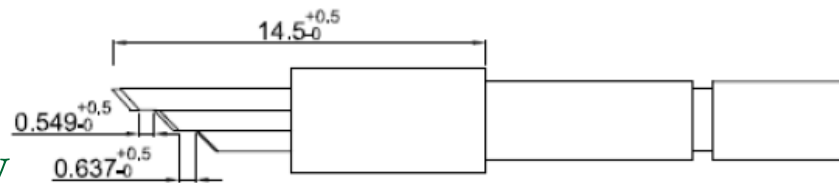
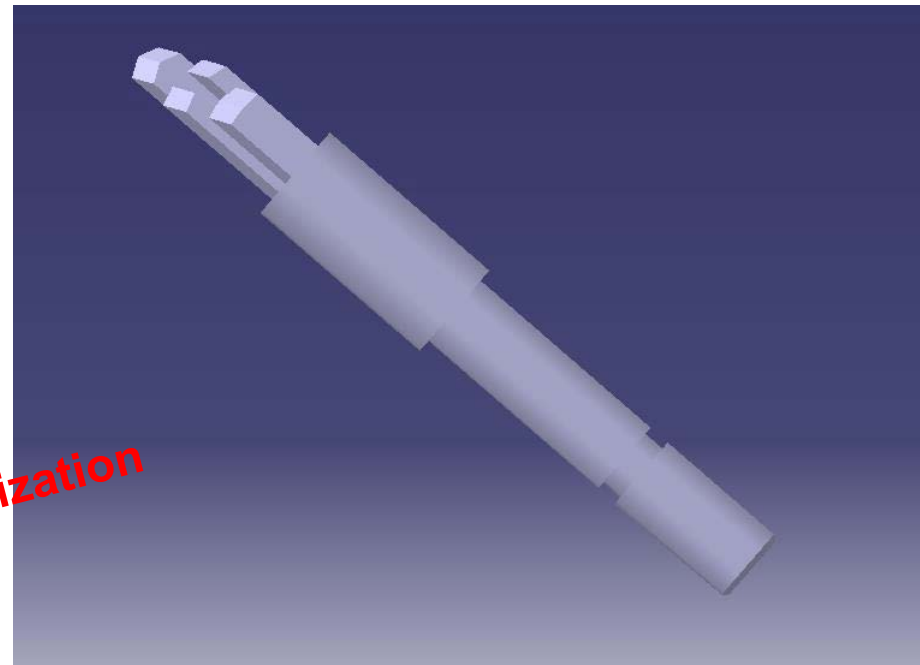


直径/mm	12	9.5	7.5	5	4	2.5	1.5	1
面积/mm ²	113.1	70.882	44.179	19.635	12.566	4.9087	1.7671	0.785
道数	6648	5990	5717	4856	4177	1853	779	267
幅度/mV	1411.5	1270.6	1212.2	1027.8	882.47	384.9	154.96	45.34



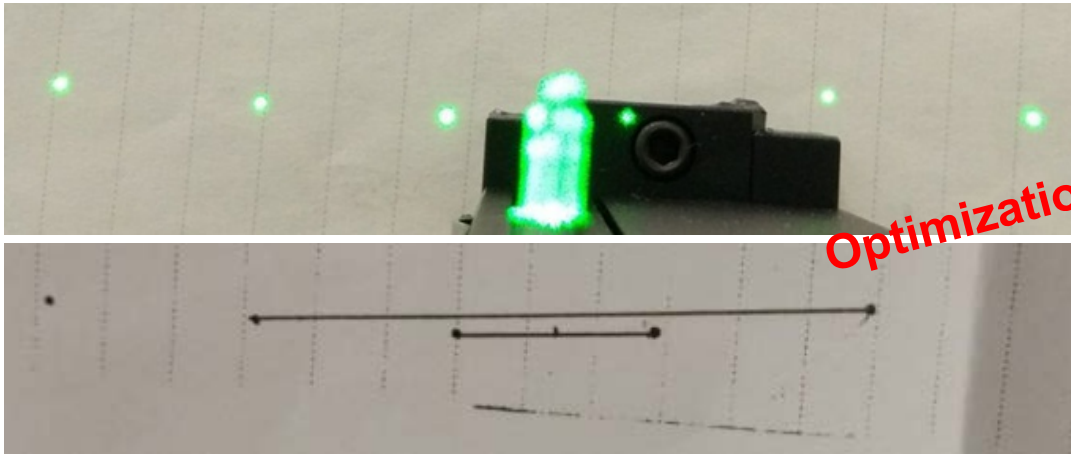
Divide and reflection mirrors

- ❑ Laser wave for the divide and reflection mirrors: 266nm
- ❑ Size: $\sim 0.8\text{mm} \times 0.8\text{mm}$
- ❑ Number of the divide trackers: 6 **Optimization**
- ❑ Stainless steel support integrated the laser mirrors
- ❑ Reflection efficiency: $>99\% @ 266\text{nm}$
- ❑ Reflection position accuracy $1/30$ degree

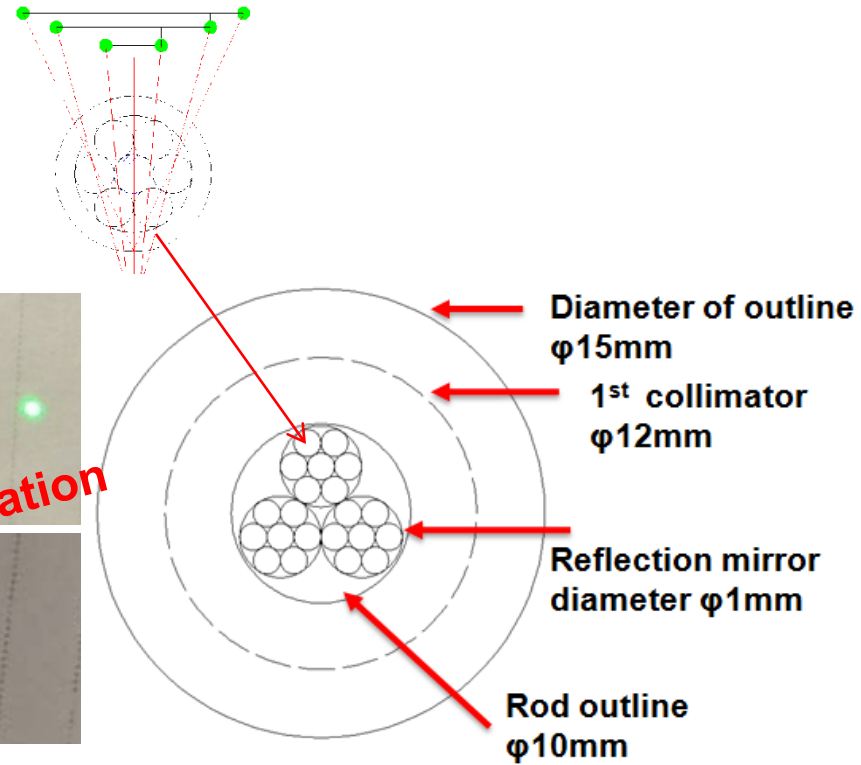


Mirrors test with 266nm

Test:



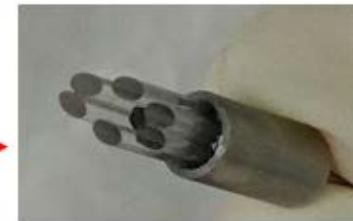
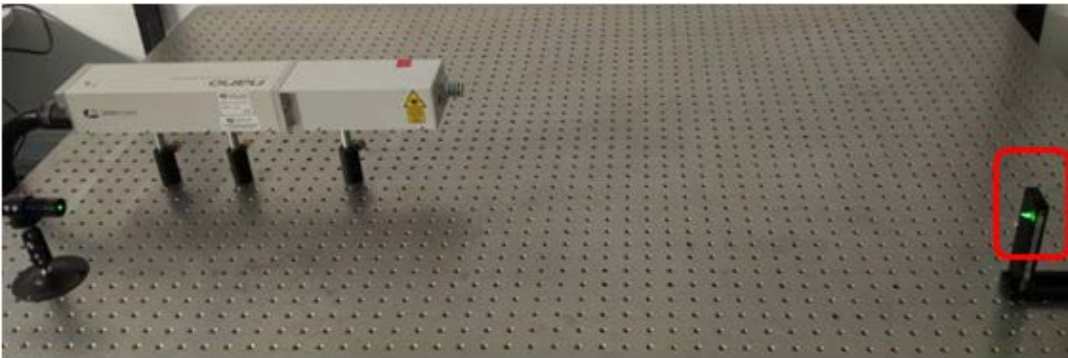
Optimization



Report of the mirrors:

Reflection mirror

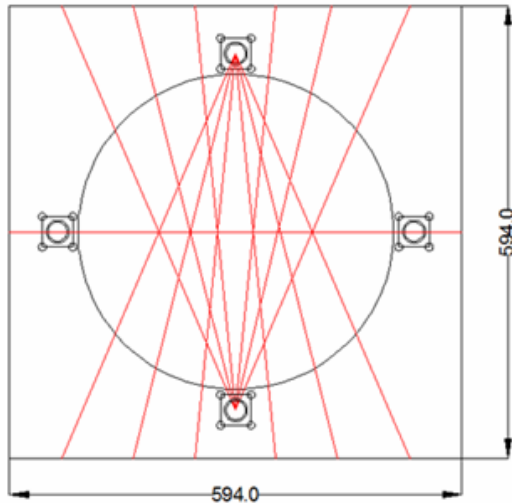
5°角	<5'	合格
15°角	<5'	合格
25°角	<5'	合格



1号	<5'	合格
2号	<5'	合格
3号	<1°	需优化
4号	<10'	需优化
5号	<5'	合格
6号	<5'	合格

Laser map in drift length

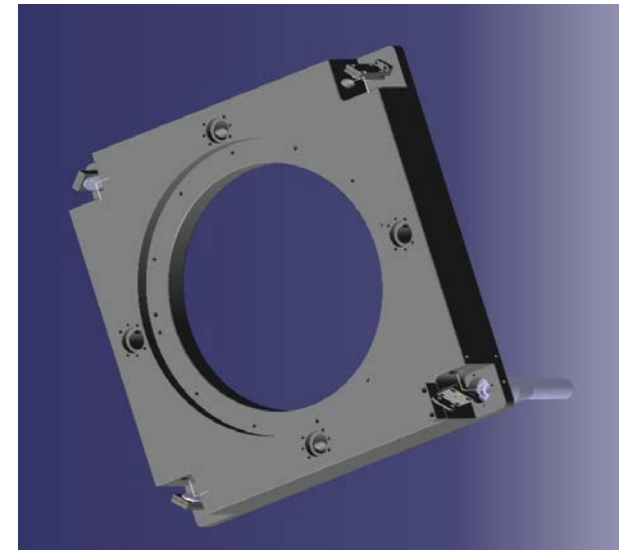
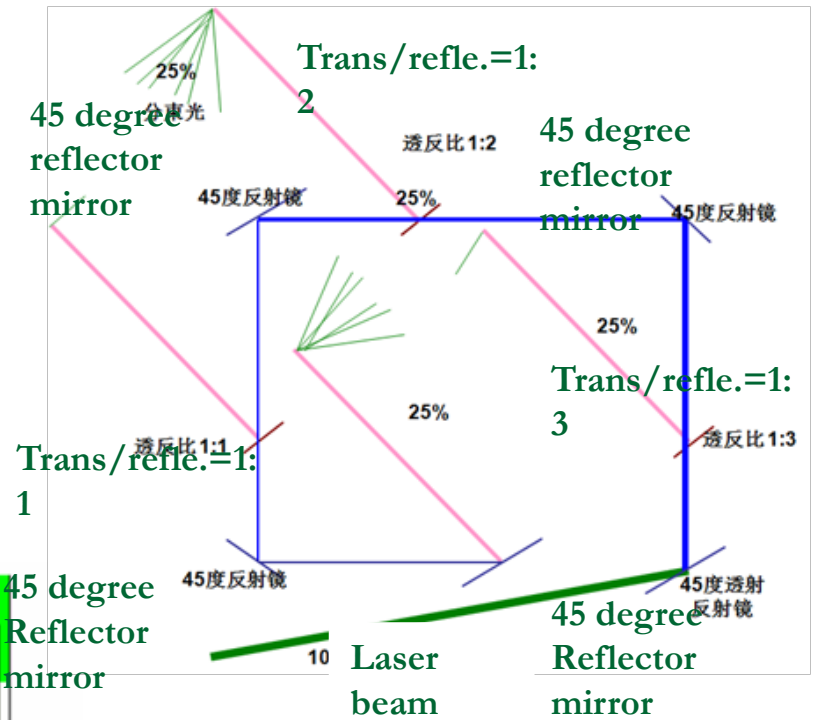
- Laser wave: 266nm
- Size: $\sim 0.85\text{mm} \times 0.85\text{mm}$
- Transmission and reflection mirrors
- Aluminum board integrated the laser device and supports



x-y方向激光光束投影分布

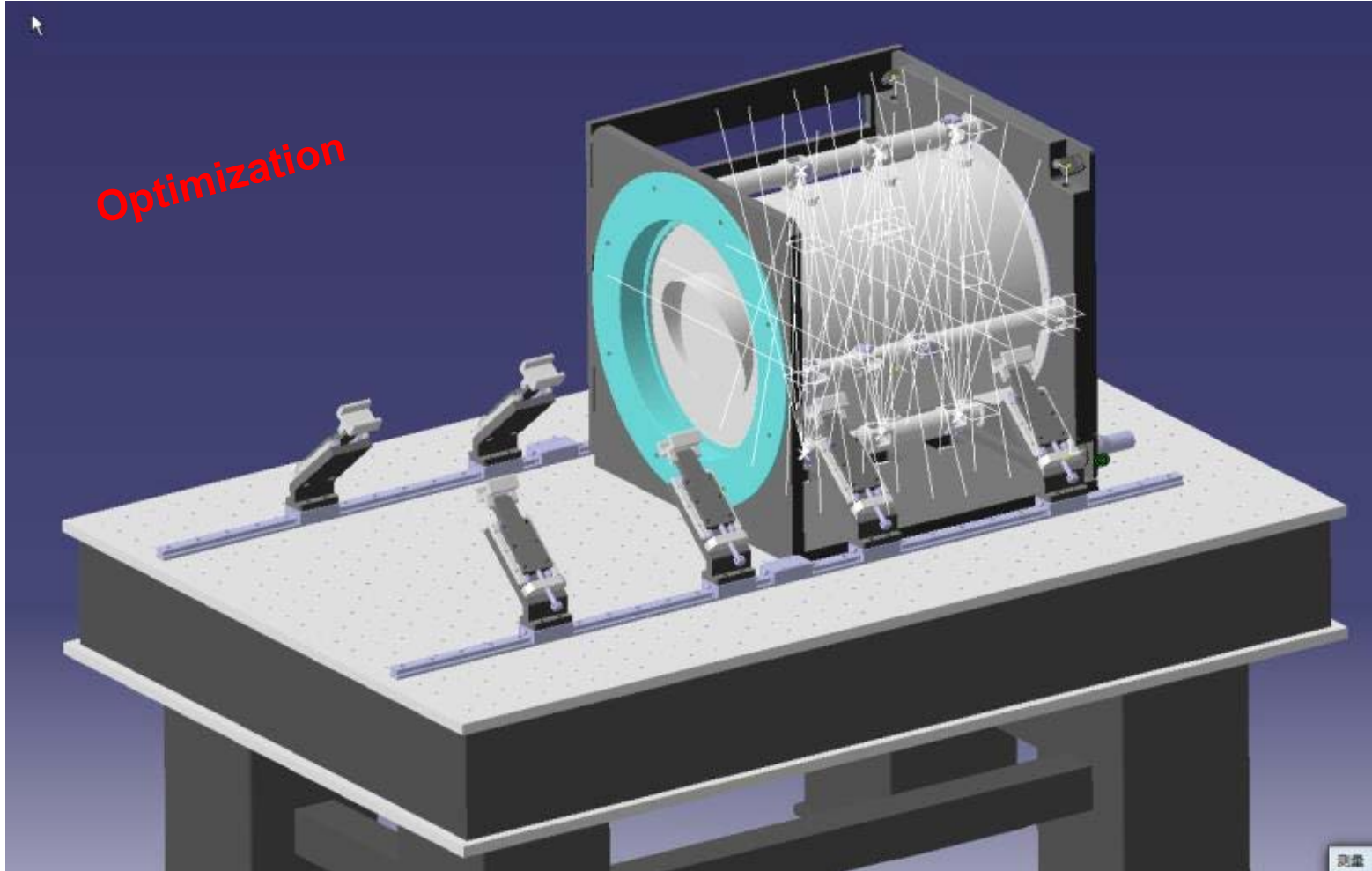


z方向激光光束投影分布



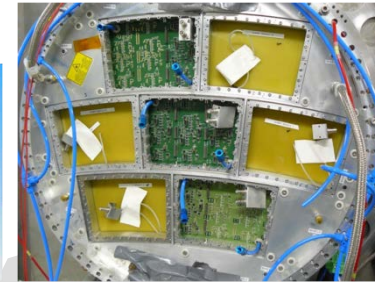
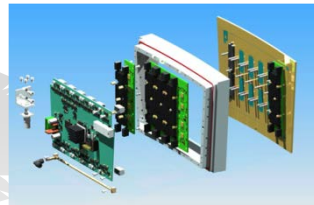
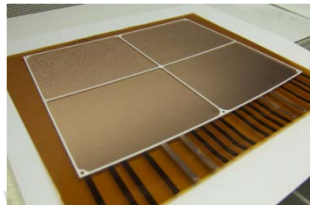
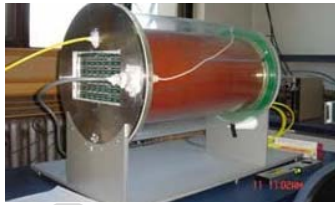
Aluminum board integrated the laser system

Design of the prototype with laser (Final version)



- ❑ Support platform: 1200mm×1500mm (all size as the actual geometry)
- ❑ TPC barrel mount and re-mount with the Auxiliary brackets
- ❑ Readout board (Done), Laser mirror (Done), PCB board (Done)

Brief history



Concept study

Smaller prototype

Large prototype

Common module

2006~2010

2012

2013

2014

2015

2016

2017

2018

2019

Tsinghua starting for prototype
PCB readout design
Dr. Li bo
Prof. Yulan Li

IHEP starting for prototype
Hybrid concept for IBF
Dr. Huirong Qi
Prof. Yuanning Gao

We are in here
Hybrid prototype starting
Calibration using laser
CDR for CEPC

Thanks.